| Search Notes |
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| Application/Control No. | Applicant(s)/Patent un Reexamination | der |
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| 10/816,006 | TANIGAWA, KOUICH | 11 |
| Examiner | Art Unit | |
| W David Coleman | 2823 | |

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| | SEAR | CHED | |
| Class | Subclass | Date | Examiner |
| 257 | 294 | 10/4/2005 | WDC |
| 257 | E33.068 | 10/4/2005 | WDC |
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| INT | INTERFERENCE SEARCHED | | |
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| Class | Subclass | Date | Examiner |
| 257 | 294 | 10/4/2005 | WDC |
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| SEARCH NOT (INCLUDING SEARCH) | |) |
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| | DATE | EXMR |
| EAST 2.0.1 Applicant forms a convex lens containin p-doped silicon nitride or p-type silicon dioxide | 10/4/2005 | WDC |
| data bases searched; USPUBS; USPAT; EPO; JPO; Derwent; IBMTDB | 10/4/2005 | WDC |
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